

L Number	Hits	Search Text	DB	Time stamp
1	24	((electrode anode cathode) with anneal\$3).ti.	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:47
2	1	((electrode anode cathode) with anneal\$3).ti.) and (gas discharge excimer) with laser	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:47
3	24	((electrode anode cathode) with anneal\$4).ti.	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:47
4	1286	((electrode anode cathode) with heat\$4).ti.	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:48
5	7	((electrode anode cathode) with heat\$4).ti.) and (gas discharge excimer) with laser	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:48
6	1825	((electrode anode cathode) with machin\$4).ti.	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:48
7	7	((electrode anode cathode) with machin\$4).ti.) and (gas discharge excimer) with laser	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:49
8	0	((electrode anode cathode) with machin\$4).ti.) and (gas discharge excimer) with laser) and anneal\$4	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:49
-	5565	((electrode anode cathode) with anneal\$3)	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:44
-	61	((electrode anode cathode) with anneal\$3)) and (anneal\$4 with machin\$4)	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:19
-	52	((electrode anode cathode) with anneal\$3)) and ((gas discharge) adj3 laser)	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:26
-	75	((electrode anode cathode) with anneal\$3)) and 372/\$.ccls.	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:26
-	75	((electrode anode cathode) with anneal\$3)) and 372/\$.ccls.) and ((electrode anode cathode) same (machin\$4 form\$5))	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:27
-	57	((electrode anode cathode) with anneal\$3)) and 372/\$.ccls.) and ((electrode anode cathode) same (machin\$4 formation forming))	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:28
-	52	((electrode anode cathode) with anneal\$3)) and 372/\$.ccls.) and ((electrode anode cathode) with (machin\$4 formation forming))	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:33
-	1721	(372/55-65).CCLS.	USPAT	2003/02/21 19:33
-	5	((372/55-65).CCLS.) and ((electrode anode cathode) with anneal\$3)	USPAT; EPO; JPO; IBM_TDB	2003/02/21 19:33
-	523	(372/87).CCLS.	USPAT; US-PGPUB	2003/06/10 17:05
-	12	((372/87).CCLS.) and anneal\$4 and (machin\$4 form\$4)	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:09
-	3	((372/87).CCLS.) and (electrode cathode anode) with stress) and anneal\$4	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:09
-	26	((372/87).CCLS.) and (electrode cathode anode) with stress	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:14

-	7	((372/87).CCLS.) and surface with stress	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:17
-	1	((372/87).CCLS.) and grain with boundary	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:18
-	0	(electrode cathode anode) and (gas discharge excimer) near3 laser	USPAT; EPO; JPO; IBM_TDB	2003/06/10 17:19